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Journal Physical Review Letters, 117(3)

ISSN

0031-9007 1079-7114

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Publication Date

2016-07-14

DOI

10.1103/PhysRevLett.117.037602

Peer reviewed

Probing the Metal-Insulator Transition in BaTiO₃ by Electrostatic Doping

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(Received 3 March 2016; revised manuscript received 11 April 2016; published 14 July 2016)

The metal-to-insulator transition in BaTiO₃ is investigated using electrostatic doping, which avoids effects from disorder and strain that would accompany chemical doping. SmTiO₃/BaTiO₃/SrTiO₃ heterostructures are doped with a constant sheet carrier density of 3×10^{14} cm⁻² that is introduced via the polar SmTiO₃/BaTiO₃ interface. Below a critical BaTiO₃ thickness, the structures exhibit metallic behavior with high carrier mobilities at low temperatures, similar to SmTiO₃/SrTiO₃ lattice parameters increase to a value consistent with a strained, tetragonal unit cell, the structures are insulating below ~125 K, and the mobility drops by more than an order of magnitude, indicating self-trapping of carriers. The results shed light on the interplay between charge carriers and ferroelectricity.

DOI: 10.1103/PhysRevLett.117.037602

The coexistence of ferroelectric and metallic behavior has been a subject of fundamental interest since at least the 1960s [1–5]. The modern understanding of ferroelectric materials such as BaTiO₃ shows that they rely on an unstable transverse optical (TO) phonon mode and large splitting of the TO and longitudinal optical (LO) modes [6]. Free carriers screen the long-range Coulomb interactions that give rise to the LO-TO splitting [7] and, thus, are expected to destabilize ferroelectricity [6,8]. An important question, which is also relevant for practical applications, is, therefore, what happens when charge carriers are introduced into a ferroelectric, for example, by doping. In $BaTiO_3$, which is a prototypical ferroelectric, some studies indicate that ferroelectricity and metallic behavior may coexist [3,9], while others have suggested that they only do so in separated regions [10]. A related observation is that doped ferroelectric single crystals and ceramics require very high doping levels to induce an insulator-tometal transition [11-13]. This appears to be consistent with the picture that ferroelectricity and metallicity cannot easily coexist. The nature of the doped ferroelectric is crucial for understanding how free carriers and ferroelectric polarization interact. For example, prior studies use chemically doped samples, which induce large amounts of disorder. Thus, not surprisingly, disorder has been invoked as an important factor in promoting the insulating state [12,13]. Furthermore, large concentrations of dopant atoms may also introduce lattice distortions that may contribute to destabilizing ferroelectricity. Improved understanding could be obtained if carriers could be introduced in a ferroelectric without chemical doping, thereby avoiding the structural distortion and disorder effects associated with foreign atoms.

Oxide heterostructures allow for introducing charge carriers by purely electrostatic means [14,15]. For example, the polar discontinuity at interfaces between the insulators

 $RTiO_3$ (*R* is a trivalent rare earth ion, such as Sm or Gd), and SrTiO₃ has been used to electrostatically introduce large sheet carrier densities ($\sim 3 \times 10^{14} \text{ cm}^{-2}$) into SrTiO₃ [16,17] to study (Mott) metal-insulator transitions (MITs) [18-23]. In such two-dimensional electron liquids (2DELs), a substantial portion of the carriers is confined near the interface, in addition to more weakly confined electrons that spread into the $SrTiO_3$ [24–28]. The conduction band alignments [29] prevent carriers from spreading into the RTiO₃ [16]. Here, we use the polar SmTiO₃/BaTiO₃ interface to introduce charge carriers into SmTiO₃/BaTiO₃/SrTiO₃ heterostructures, as shown schematically in Fig. 1(a). BaTiO₃ films of increasing thickness are inserted into the SmTiO₃/SrTiO₃ interface. For paraelectric BaTiO₃, the carrier density and distribution are expected to be similar to structures without BaTiO₃ due to similar fixed polar charges, material properties, and band offsets; see Fig. 1(b). We show that above a critical BaTiO₃ thickness corresponding to approximately two unit cells (u.c), the structure and transport properties abruptly change, consistent with the appearance of ferroelectricity in the BaTiO₃. We discuss the carrier transport in this regime and show that it provides insights into the interaction between mobile carriers and ferroelectricity and the nature of the insulating state.

Layers were grown by hybrid molecular beam epitaxy (MBE) on (001) (LaAlO₃)_{0.3}(Sr₂AlTaO₆)_{0.7}(LSAT), as described elsewhere [34,35] and are coherently strained to the LSAT substrate (lattice parameter: 0.386 nm). The thickness of the SmTiO₃ and SrTiO₃ layers is kept constant at 5 and 20 nm, respectively, and the BaTiO₃ thickness is varied between $\frac{1}{2}$ and 13 u.c. In the following, we specify the BaTiO₃ thickness by the number of BaO planes it contains; see Fig. 1(a). Oscillations in the intensity of *in situ* reflection high-energy electron diffraction (RHEED) patterns [31] of all layers indicated layer-by-layer growth and allowed for precise thickness control during growth.



FIG. 1. (a) Schematic of the heterostructure. The thickness of the $BaTiO_3$ layer is specified in terms of the number of BaO layers it contains. The gray-shaded area indicates the 2DEL, which spreads into the $BaTiO_3/SrTiO_3$ layers. (b),(c) Calculated conduction band profiles and 2DEL charge distributions for the $SmTiO_3/BaTiO_3/SrTiO_3$ heterostructures, with (b) two u.c. (3 BaO layers) of a paraelectric $BaTiO_3$ layer and (c) seven u.c. (8 BaO layers) of a ferroelectric $BaTiO_3$ layer. The calculations were performed with a one-dimensional Poisson-Schrödinger solver [30] using the parameters described in the Supplemental Material [31]. (d) On-axis XRD patterns of the 5-nm-SmTiO_3/x-BaO (BaTiO_3)/20-nm-SrTiO_3/LSAT heterostructures. The dashed lines indicate the expected peak positions for individual layers coherently strained to a LSAT substrate.

On-axis x-ray diffraction (XRD) showed only film and substrate reflections [Fig. 1(d)]. XRD, oscillations in RHEED intensity, and high-angle annular dark-field scanning transmission electron microscopy (HAADF STEM) were used to confirm the thicknesses and structural quality of the heterostructures. All samples exhibit Laue thickness fringes in XRD, indicating smooth interfaces and high quality epitaxy. The 20 nm SrTiO₃ films give rise to closely spaced Laue fringes seen in all samples in Fig. 1(d) and widely spaced fringes from the 5 nm SmTiO₃ layer are visible. For larger BaTiO₃ thicknesses, the peaks from the BaTiO₃ interfere, and the interference pattern becomes more complex.

For electrical characterization (resistivity and Hall measurements) in a physical property measurement system (Quantum Design PPMS DynaCool), 50-nm-Ti/400-nm-Au Ohmic contacts were deposited in van der Pauw geometry on the SmTiO₃ layer. The Hall voltage as a function of magnetic field was linear up to ± 9 T, similar to $RTiO_3/SrTiO_3$ interfaces [16,36]. Ferroelectric hysteresis loops of BaTiO₃ films were measured by piezo-force microscopy (PFM) and capacitance-voltage (*C-V*) measurements [31]. For HAADF STEM, cross-section samples were prepared by focused ion beam thinning and imaged on a FEI Titan S/TEM operated at 300 kV with a 9.6 mrad

convergence angle. The images shown here consisted of 100 fast-scan images, which were acquired with a 3 μ s dwell time and 512 × 512 pixels, and averaged using subpixel cross-correlation to reduce the effect of drift and scan distortions.

All samples exhibited Hall sheet carrier densities (n_{2D}) at 300 K of $\sim 3 \times 10^{14}$ cm⁻² [Fig. 2(a)], independent of the BaTiO₃ thickness. Thus, a 2DEL forms at the SmTiO₃/BaTiO₃ interface, with n_{2D} corresponding to the value that compensates the fixed polar charge at the interface. Aside from a small decrease for thicker films, n_{2D} is almost independent of the temperature (T). The T dependence of the sheet resistance R_s [Fig. 2(b)] for samples with BaTiO₃ thicknesses of one to three BaO layers shows metallic behavior (defined as $\delta R_S / \delta T > 0$), except for a slight upturn at low temperatures that could be weak localization. A pronounced increase in R_s occurs for samples with more than four BaO layers and $\delta R_S/\delta T < 0$ below 125 K. The Hall mobility, μ , for samples with BaTiO₃ thicknesses below four BaO layers is similar to that of $RTiO_3/SrTiO_3$ interfaces [Fig. 2(c)] [37]. At low T, μ of RTiO₃/SrTiO₃ interfaces is dominated by interface roughness scattering, while at higher T, it is limited by electron-electron scattering $(\mu^{-1} \sim T^2)$ [37]. SmTiO₃/ BaTiO₃/SrTiO₃ heterostructures show similar transport



FIG. 2. (a) Sheet carrier density n_{2D} , (b) sheet resistance R_s , and (c) mobility μ as a function of temperature *T*, for SmTiO₃/BaTiO₃/SrTiO₃/(001)LSAT samples with different BaTiO₃ thicknesses (specified in number of BaO layers). The dashed lines are guides to the eye, and the solid lines in (c) are fits to the data. For the three thinnest BaTiO₃ structures, fits of form $\mu^{-1} = \mu_0^{-1} + \alpha T^2$ were used and resulted in (goodness-of-fit) chi-squared values of less than 0.006. Such fits yielded an increased chi-squared value for the four BaO sample (0.01). Including LO-phonon scattering ($\mu^{-1} = \mu_0^{-1} + \alpha T^2 + \mu_{LO}^{-1}$) reduced the chi-squared value to 0.003, and the average energy of the LO phonon obtained from the fit is 50 meV. The drop in the mobility at low temperatures for this sample is due to the low μ_0 .

characteristics, but only for BaTiO₃ thicknesses less than four BaO layers. This can be seen from the fits in Fig. 2(c), which show that the data are described as $\mu^{-1} = \mu_0^{-1} + \alpha T^2$, where μ_0 is the disorder (defects, interface roughness, etc.) limited mobility, and α is the strength of electron-electron scattering, which had values

similar to that of the $RTiO_3/SrTiO_3$ interfaces $(1.2-1.9 \times 10^{-6} \text{ Vs cm}^{-2} \text{ K}^{-2})$. The absence of LO-phonon mode scattering, which limits the mobility of bulk doped SrTiO₃ at room temperature, indicates screening by the large density of free carriers [37]. To describe the data of the sample with four BaO layers, LO-phonon scattering is included to obtain a fit of comparable quality (see Fig. 2), i.e., $\mu^{-1} = \mu_0^{-1} + \alpha T^2 + \mu_{\text{LO}}^{-1}$, where μ_{LO} is the LO-phonon scattering limited mobility. It is given as $\mu_{\rm LO} = (K_{\rm LO}/\hbar\omega_{\rm LO})[\exp(\hbar\omega_{\rm LO}/k_BT) - 1]$, where \hbar is the reduced Planck's constant, k_B the Boltzmann constant, $\hbar\omega_{\rm LO}$ the (effective) energy of the LO phonon(s), and $K_{\rm LO}$ is given in Ref. [38]. Furthermore, the four BaO layer sample shows a large decrease in μ_0 by a factor of 5. For thicknesses greater than four BaO layers, the mobility drops further, to below 10 $\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$. For these samples, the low-temperature mobility increases initially with the temperature, then decreases with further increase in the



FIG. 3. (a) HAADF STEM cross sections of eight BaO (left) and three BaO (right) thick layers of BaTiO₃. The SrTiO₃ and SmTiO₃ layers are to the left and right of the BaTiO₃, respectively. The arrows mark the approximate interface boundaries. (b) Maps of unit cell lattice parameters along the out-of-plane and in-plane directions, normalized to the lattice parameter of the three layers of SrTiO₃ farthest away from the BaTiO₃. Only SrTiO₃ and BaTiO₃ layers are mapped. (c) Averaged (parallel to the interface) in-plane (orange circle) and out-of-plane (blue square) lattice parameters from (b). The dashed lines indicate the theoretically expected value for compressively strained, *c*-axis oriented, tetragonal BaTiO₃ on a LSAT substrate.

temperature. No attempt was made to fit the mobility data for the samples with greater than four BaO layers.

Figure 3(a) shows HAADF STEM cross-section images of samples with nominally eight BaO layers (left) and three BaO layers (right), respectively. Thickness variations of ± 1 monolayer are associated with steps. The average number of BaO layers over the entire TEM sample matches the thickness calibrated using RHEED oscillations. Abrupt $SrTiO_3/BaTiO_3$ interfaces with clear atomic number (Z) contrast can be seen. The BaTiO₃/SmTiO₃ interface has a smaller Z difference and is located using the A-site cation off centering in the SmTiO₃, not present in BaTiO₃ [19]. Figure 3(b) shows a map of the relative out-of-plane and in-plane lattice parameters of the SrTiO₃ and BaTiO₃ layers measured from Fig. 3(a), normalized to the SrTiO₃. The inplane values are ~ 1.00 , consistent with coherently strained films. The out-of-plane values are all >1.00 in the BaTiO₃. The eight BaO sample shows a relative out-of-plane value of ~ 1.057 in the interior, which matches the theoretically expected value for compressively strained, *c*-axis-oriented, tetragonal BaTiO₃ [dashed lines in Fig. 3(c)]. The out-ofplane values are reduced near the interfaces and remain completely below the theoretically predicted value in the three BaO layer film, indicating reduced tetragonality.

We next discuss the origins of the different transport characteristics of samples with less than and greater than four BaO layers, respectively. We note that all BaTiO₃ films, independent of their thickness, were electrostatically doped due to the polar discontinuity with SmTiO₃. The samples show metallic behavior and carrier mobilities consistent with band conduction only when the BaTiO₃ is extremely thin (≤ 2 u.c.s). Such thin layers are characterized by reduced tetragonality and the absence of LO-phonon scattering at high temperature, indicating that these layers are not ferroelectric. "Dead layers" of a few u.c. are common for ferroelectric films [39,40]. The HAADF STEM images show that they are correlated with a reduced tetragonality of the unstrained unit cell. The transport characteristics of samples with thin BaTiO₃, including the mobilities and the temperature dependence are comparable to RTiO₃/SrTiO₃ samples [16,37], indicating that 2DELs at interfaces with *paraelectric* BaTiO₃ do not have fundamentally different properties.

Thicker BaTiO₃ films (more than four BaO layers) show increased lattice distortion, consistent with a tetragonal unstrained unit cell and a ferroelectric film. Although the measurement of polarization switching, which is the only definitive proof for ferroelectricity, is not possible for such conductive layers, the results, nevertheless, suggest the microscopic conditions for ferroelectricity exist (tetragonal distortion, LO-phonon scattering in the four BaO sample). Hysteresis in PFM and *C-V* measurements of similar structures indicate ferroelectricity in BaTiO₃ layers of comparable thickness and grown by the same method [31]. Furthermore, the transport characteristics of structures with thicker BaTiO₃ films (greater than four layers) imply that the carriers cease to spread into the SrTiO₃, as in that case, transport would show high-mobility, metallic characteristics. This can be explained with the presence of the internal ferroelectric polarization field, which causes a change in the spatial distribution of the charge carriers compared to a structure with paraelectric BaTiO₃. Specifically, the calculations in Fig. 1(c) show that carriers are located only within the BaTiO₃ layer when a ferroelectric polarization is present. The decrease in μ_0 of the four BaO layer sample can, thus be explained with the redistribution of the portion of the 2DEL that was located far in the SrTiO₃ closer to the SmTiO₃/BaTiO₃ interface (where the carriers suffer from interface roughness scattering).

The very low mobilities $(1 - 10 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1})$ of carriers in ferroelectric samples with greater than four BaO layers are consistent with self-trapping of carriers (also known as strong-coupling polarons [41]). In particular, at low temperatures, the mobility increases initially as the temperature is raised. This cannot be described by a temperatureindependent disorder term μ_0 . Furthermore, the samples show insulating characteristics in this regime, despite the fact that the sheet resistances remain below the Mott-Ioffe-Regel limit of ~10 k Ω/\Box , where strong localization must occur [42]. The low mobilities are similar to those of single crystal, doped BaTiO₃ [43]; thus, the very sluggish conduction, typical of polarons, appears to be a general feature of carriers in ferroelectric BaTiO₃, independent of how the carriers are introduced, i.e., chemical vs electrostatic doping, i.e., the degree and type of disorder. The temperature dependence of the transport characteristics of selftrapped carriers can be complicated [44], and standard models for transport of strong-coupling polarons often fail for real materials [45].

The results, thus, show that the appearance of ferroelectricity coincides with the transition from a high-mobility, metallic state to a low-mobility, high-resistance state, with insulating characteristics at low temperature. As the sheet carrier density and other parameters are kept constant, this transition reflects the intrinsic interactions between (free, mobile) charge carriers and the ferroelectric polarization. The ferroelectric film does not tolerate mobile free carriers: carriers are pushed out of the interior towards the interface, where they conduct with low mobility and the temperature dependence is consistent with self-trapping. The MIT is, thus, reminiscent of a Mott-type transition, in the sense that it occurs when the long-range Coulomb forces are insufficiently screened. With regards to the question as to whether ferroelectricity and mobile carriers can coexist, the answer appears to be ves but not with conventional, metallic conduction within the bulk of the ferroelectric. Finally, the method of electrostatic doping may be useful in the future, for example, in understanding other intrinsic aspects of polarons for which a quantitative understanding is often missing.

The authors gratefully acknowledge very useful discussions with David Emin and Boris Shklovskii. This work was supported in part by the MRSEC Program of the NSF under Grant No. DMR 1121053, which also supported the MRL Shared Experimental Facilities used in this work, and in part by the Center for Low Energy Systems Technology, one of six centers of STARnet, a Semiconductor Research Corporation program sponsored by MARCO and DARPA. The microscopy work was supported by the DOE (Grant No. DEFG02-02ER45994).

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